

## UNITED STATES PATENT AND TRADEMARK OFFICE

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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/764,457	01/19/2001	Sachio Uto	520.39440X00	7365
20457 7:	590 02/27/2003			
ANTONELLI TERRY STOUT AND KRAUS			EXAMINER	
SUITE 1800 1300 NORTH SEVENTEENTH STREET ARLINGTON, VA 22209		EET	JOHNSTON, PHILLIP A	
			ART UNIT	PAPER NUMBER
		_	2001	

DATE MAILED: 02/27/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)			
Office Action Summary						
		09/764,457	UTO ET AL.			
		Examiner	Art Unit			
	The MAILING DATE of this communication app	Phillip A Johnston	2881			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133).  - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).						
1)	Responsive to communication(s) filed on					
2a)□		· s action is non-final.				
3)	,					
closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213. <b>Disposition of Claims</b>						
4)⊠ Claim(s) <u>1-20</u> is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.						
5)	5) Claim(s) is/are allowed.					
6)⊠	6)⊠ Claim(s) <u>1-20</u> is/are rejected.					
7)	Claim(s) is/are objected to.					
8) Claim(s) are subject to restriction and/or election requirement.						
	on Papers					
9) The specification is objected to by the Examiner.						
10)⊠ The drawing(s) filed on <u>19 January 2001</u> is/are: a)⊠ accepted or b)⊡ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11) ☐ The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved by the Examiner.  If approved, corrected drawings are required in reply to this Office action.						
12) The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13)  Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
	☑ All b)☐ Some * c)☐ None of:	priority under 00 0.0.0. g 175(a)	-(d) or (i).			
	1.⊠ Certified copies of the priority documents	have been received				
	2. Certified copies of the priority documents have been received in Application No					
	3. Copies of the certified copies of the priority documents have been received in this National Stage					
* Se	application from the International Bureau (PCT Rule 17.2(a)).  * See the attached detailed Office action for a list of the certified copies not received.					
14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application).						
a) ☐ The translation of the foreign language provisional application has been received.  15)☐ Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121.						
Attachment(s)						
2) 🔲 Notice	of References Cited (PTO-892) of Draftsperson's Patent Drawing Review (PTO-948) ation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Informal Pa	PTO-413) Paper No(s) stent Application (PTO-152)			

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## **Detailed Action**

1. The previous Office action has been vacated in view of this Office action.

## Claims Rejection – 35 U.S.C. 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which the subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1,2, and 9-19 are rejected under 35 U.S.C. 103(a) as being unpatentable over Noguchi(377), in view of Kokuchi (009).

Noguchi (377) discloses in Figure 3, an optical apparatus for defect detection that includes a stage unit 300 comprising a substrate mounting base 304, x, y and z stages 301, 302 and 303 and a stage controller 305; 3 illumination optical systems 100 having a laser-beam source 101, a beam splitter comprising a concave lens 102 and a convex lens 103 and an illumination lens 104 having a conical surface; a detection optical system 200 including a detection lens 201, a spatial filter 202, an image formation lens 203, an ND (Neutral Density) filter 207, a beam splitter 204, a polarization device 208 and one-dimensional detectors (image sensors) 205 and 206 which are each implemented typically by a TDI image sensor; an image-signal processing unit 400. The illumination optical systems 100 has light emitted by the

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laser-beam source 101, being converted into slit-shaped beams 3 which are radiated to a wafer 1 or an inspected substrate 1 mounted on the substrate mounting base 304 from 3 directions 10, 11 and 12 on a plane. See Column 14, line 47-59, and Column 15, line 27-34. In addition, the laser-beam source 101, may be a high-output YAG laser SHG for generating a second harmonic wave with a wavelength of 532 nm, which is a DUV (deep ultraviolet) laser source, as noted in Column 17, line 41-45, and Column 34, line 21.

Noguchi (377) further discloses that the invention provides an image-signal processing unit 400 characterized in that a variation (a standard deviation) among chips is computed for each pixel in the chip and used for setting a threshold value, and a defect such as a foreign particle in an area with a small variation is detected by using a small threshold value while a defect such as a foreign particle in an area with a big variation is detected by using a large threshold value. In this way, the threshold value for an area with a small variation can be reduced without being affected by an area with a big variation. An example of an area with a small variation is the memory-cell area in the case of a memory LSI. As a result, it is possible to detect an infinitesimal foreign particle with a size not exceeding 0.1um. See Column 35, line 35-48.

Kikuchi (009) discloses an ultraviolet laser apparatus that includes an optic resonator and a coherence reduction optical system, recited in Claims 2 and 17, respectively. As described in column 9, line 48-58, and column 12, line 50-55, Kikuchi (009), discloses a laser light generating device where the phase-modulated laser beam is converted by wavelength conversion means into a laser beam of a shorter

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wavelength at the same time as it is further enlarged in spectral width. The result is that the coherence distance of the laser beam is shortened to suppress the speckle noise. In this case, the post-wavelength-conversion laser light is phase-modulated since the resonant frequency of a resonator inclusive of a non-linear optical crystal is coincident with the frequency of the fundamental wavelength laser light beam, wavelength conversion is performed with a high conversion efficiency. The phase modulation is performed by phase modulation units 54, and wavelength-converted by second harmonics generating units 55 to form second harmonics for widening the spectral width. That is, temporal coherence is lowered. The generated second harmonics are then modulated by image signals by intensity modulation unit 56. Subsequently, the lowering in temporal coherence is converted into that in spatial coherence for reducing the speckle noise in the laser beam.

It would have been obvious to one of ordinary skill in the art that Noguchis'(377) defect inspection apparatus can be modified to use the laser light generating means in accordance with the teaching of Kokuchi (009) to reduce speckle. Thereby reducing the systems susceptibility to noise produced by the interference pattern, resulting in improved foreign particle detect-ability.

4. Claims 3-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over Noguchi (377), in view of Kikuchi (009), as applied to Claims 1,2, and 9-19 above, and in further view of Sandland (172)

Sandland (172), discloses environmental covers in FIG. 4A, which surround the area through which the wafer passes during inspection so as to provide environmental

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control. One such arrangement is shown in FIG. 4A where a fixed cover 107 is attached to fixed member 105 of stress frame 104, and a floating cover 111 is attached to aluminum casting 110. This creates an air lock 113 between the two overlapping covers because the interior of the wafer inspector is maintained at a positive pressure. Air passing through the air lock under pressure prevents outside contaminants from entering the inspection area, as recited in Claim 20.

It is implied herein, that maintaining the interior of the wafer inspector at a positive pressure in accordance with Sandland (172) is equivalent to "monitoring and detecting a contamination condition", as recited in Claim 20.

In addition, it is well known in the art to utilize "multi walled housing construction", as recited in Claims 3-5, to protect equipment for hermetical sealing and thermal shielding reasons, for example U.S. Patent No. 6,396,061.

Hence, it would have been obvious to anyone of ordinary skill in the art that one could design an inspection system according to Noguchi (377), and use the environmental controls in accordance with the teaching of Sandland (172), to provide a controlled environment for defect inspection, thereby reducing the probability of inspection induced defects.

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## Conclusion

5. Any inquiry concerning this communication or earlier communications should be directed to Phillip Johnston whose telephone number is (703) 305-7022. The examiner can normally be reached on Monday-Friday from 7:30 am to 4:00 pm. If attempts to reach the examiner by telephone are unsuccessful, the examiners supervisor John Lee can be reached at (703) 308-4116. The fax phone numbers are (703) 872-9318 for regular response activity, and (703) 872-9319 for after-final responses. In addition the customer service fax number is (703) 872-9317.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703 308 0956.

PJ

February 10, 2003

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